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PATENT NUMBER and ISSUE DATE

U.S. **UTILITY** Patent Application

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1006676	4 02/06/2002	359	_18	2833	Anger Die	
**APPLIC	NTS: Lee	Sang; Park J	lae; Bu Jong:	·		
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35 USC 119 conditions met ☐ yes ☐ no ` Verified and Acknowledged Examiners's initials					-0392	1
TITLE : Op		- India		<u></u>		
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VANCE MAILED		CLAIMS ALLOWED					
	Assistant Examiner	Total Claims		Print Claim for O.G			
E FEE		DRAWING					
Date Paid	7	Sheets Drwg.	Figs.Drwg.	Print Fig.			
·	Primary Examiner						
INAL	PREPARED FOR ISSUE	FOR ISSUE Application Examiner					
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	Date Paid	Primary Examiner INAL PREPARED FOR ISSUE WARNING: The information disclose Unauthorized disclosure may be prohibing Sections 122, 181 and 368, Possession of the sections 122, 181 and 368, Possession 122, 182 and 182 and 182 and 182 and 182 and	Assistant Examiner FFEE Date Paid Primary Examiner INAL PREPARED FOR ISSUE WARNING: The information disclosed herein may be Unauthorized disclosure may be prohibited by the Units Sections 122, 181 and 368, Possession outside the U.S.	Assistant Examiner DRAWING Sheets Drwg. Primary Examiner PREPARED FOR ISSUE WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Sections 122, 181 and 368, Possession outside the U.S. Patent & Training			